INTEGRATED CIRCUIT FOR PIR SMART SENSOR PRODUCTION DATA - MAR 20, 2012





Features

- Digital signal processing
- On chip supply shunt regulator
- Low power consumption
- Differential PIR sensor input
- Excellent power supply rejection
- Insensitive to RF interference
- Inputs for sensitivity and on time

Applications

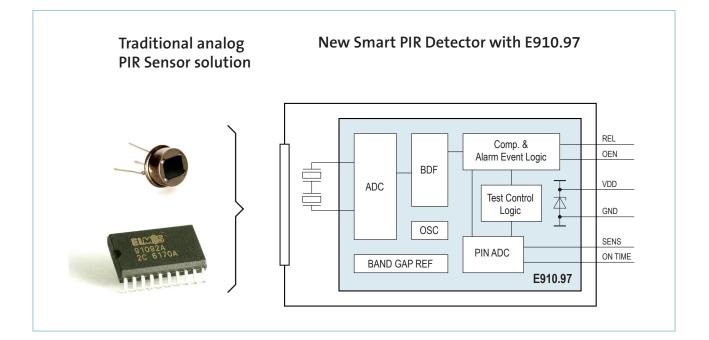
- PIR motion detection
- Intruder detection
- Occupancy detection
- Motion sensor lights

General Description

The E910.97 integrated circuit combines all required functions for a single chip Passive Infra Red (PIR) motion detector. Motion detection is signaled through the pushpull REL output. A digital input OEN enables REL output. The E910.97 interfaces directly to a PIR sensor element via a high impedance differential input. The PIR signal is converted to a 15 bit digital value. The parameters for sensitivity and timing are set by connecting the corresponding inputs to DC voltages. The voltage levels on the inputs are converted to digital values with 7 bit resolution. All signal processing is performed digitally. The E910.97 is assembled with a pyro-ceramic element in a hermetically sealed package.

Digital Sensor Assembly with E910.97

The E910.97 PIR Controller results in a single component Solution for a Motion Sensor



ELMOS Semiconductor AG reserves the right to change the detail specifications as may be required to permit improvements in the design of its products

ELMOS Support

Headquarters

ELMOS Semiconductor AG Heinrich-Hertz-Str. 1 44227 Dortmund (Germany) Phone: +49 (0) 231 / 75 49-100 Fax: +49 (0) 231 / 75 49-149 sales@elmos.com www.elmos.com

Regional Sales and

Application Support Office Munich

ELMOS Semiconductor AG Am Gefluegelhof 12 85716 Unterschleißheim/Eching (Germany) Phone: +49 (0) 89 / 31 83 70-0 Fax: +49 (0) 89 / 31 83 70-31 sales-elmuc@elmos.com

Sales and Application Support Office

North America ELMOS NA. Inc. 32255 Northwestern Highway, Suite 45 Farmington Hills, MI 48334 (United States)

Phone: +1 (0) 248 / 8 65 32 00 elna-sales@elmosna.com

Sales and Application Support Office

Korea and Japan

ELMOS Korea Suite 1907 Park View Office Tower 6 Jeongja-dong, Bundang-gu, Seongnam-si, Kyonggi-do, 463-863 Republic of Korea Phone: +82 (0)31 / 7 14 11 31 jin-koo.lee@elmos.com

Sales and Application Support Office

China ELMOS Semiconductor Technology (Shanghai) Co., Ltd. Unit London, 1BF GC Tower, No. 1088 YuanShen Road, Pudong New District, Shanghai, PR China, 200122 Phone: +86 (0) 21 / 5178 5178 sales_china@elmos.com

中国地区销售与应用支持

艾尔默斯半导体技术(上海)有限公司 中国上海浦东新区源深路1088号 葛洲坝大厦1B楼伦敦单元,200122 电话:+86(0)21/51785178 sales_china@elmos.com

Sales and Application Support Office Singapore

ELMOS Semiconductor Singapore Pte Ltd. 60 Alexandra Terrace #09-31 The Comtech (Singapore 118502) Phone: +65 (0) 663 / 5 11 41 Fax: +65 (0) 663 / 5 11 40 sales@elmos.com

Application Support Office

South Africa

Microsystems On Silicon (PTY) Ltd. Pretoria, South Africa Tel: +27 (12) 348 8367 Fax: +27 (12) 348 1790 sales@mos.co.za

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